

Si Tip Field Emission Electron Source for Applications in Ionisation Vacuum Gauges

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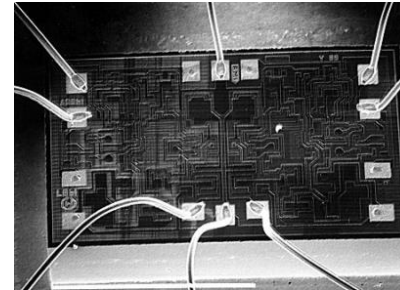
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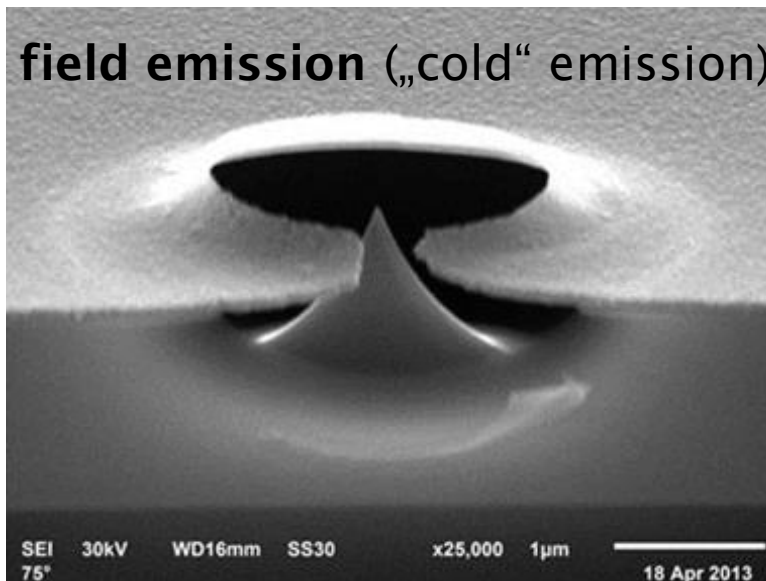
1. Motivation: Vacuum nanoelectronics



Thermionic emission
in electron tubes
($T > 1000^\circ\text{C}$)



Si-technology



field emission („cold“ emission)

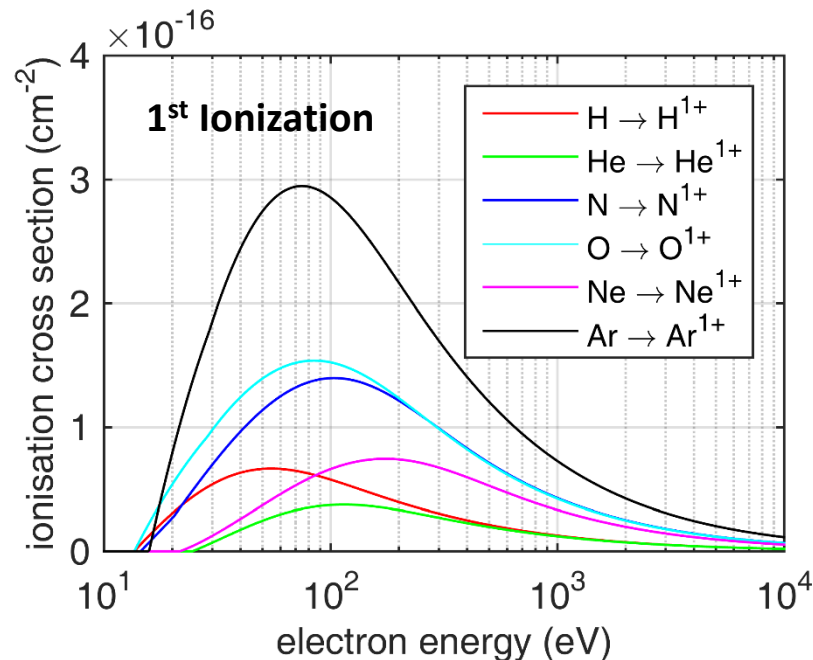
New possibilities of
vacuum nanoelectronics:
**Fabrication of
miniaturized field
emission cathodes**

1. Motivation: Vacuum nanoelectronics

Application: Ionization vacuum gauge

Ionization process is most efficient for rather low electron energies

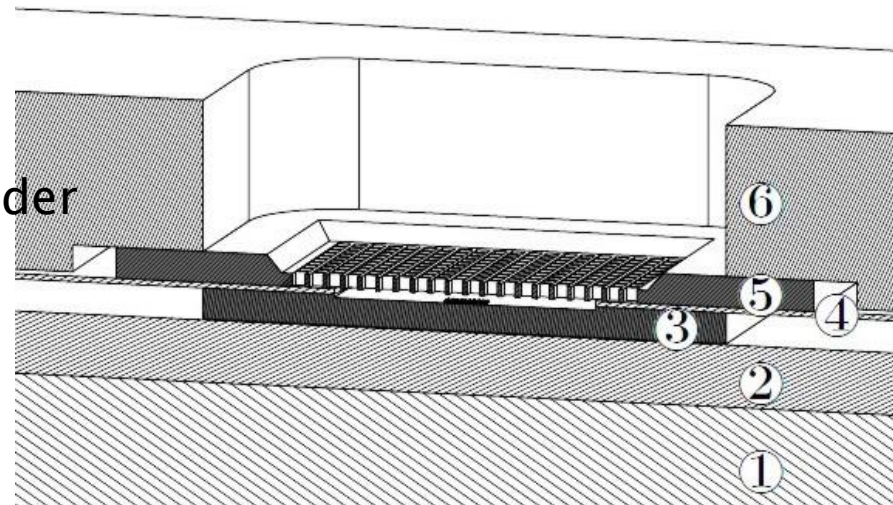
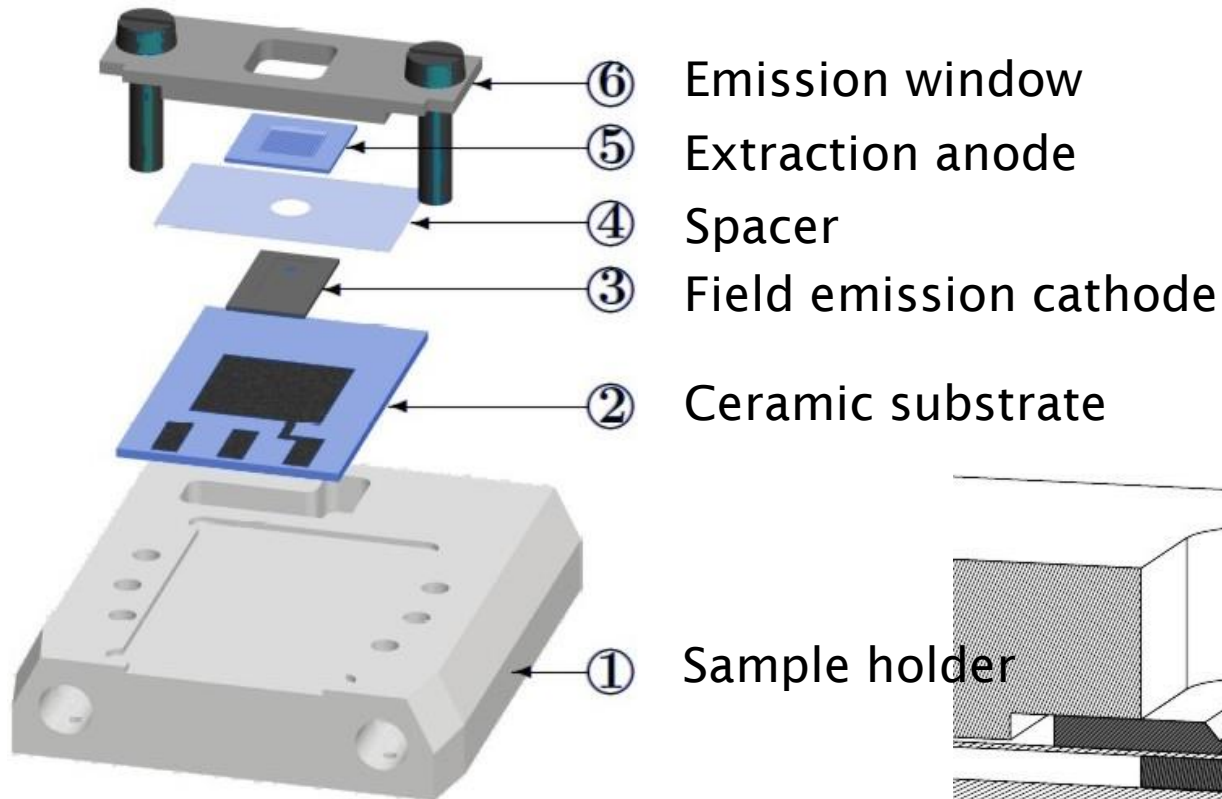
Ionization cross section vs. electron energy:



Requirements for the application:

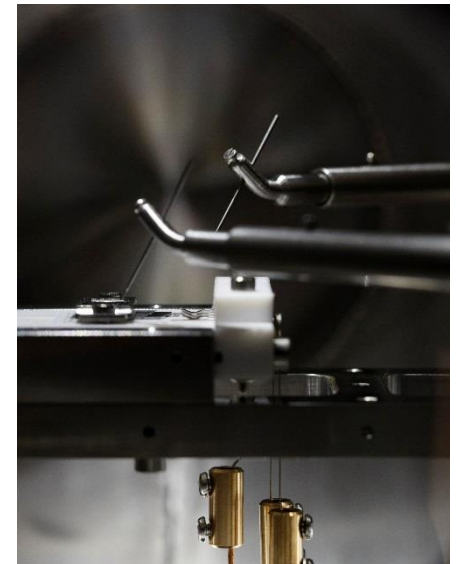
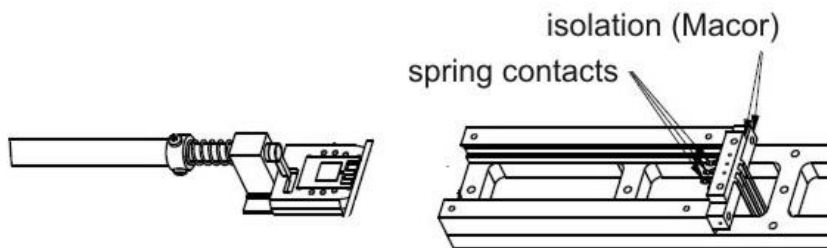
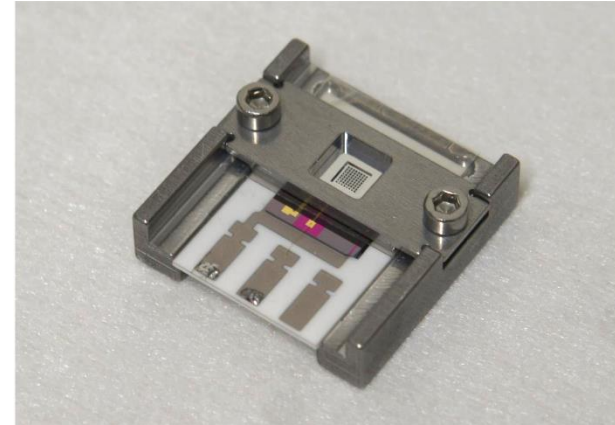
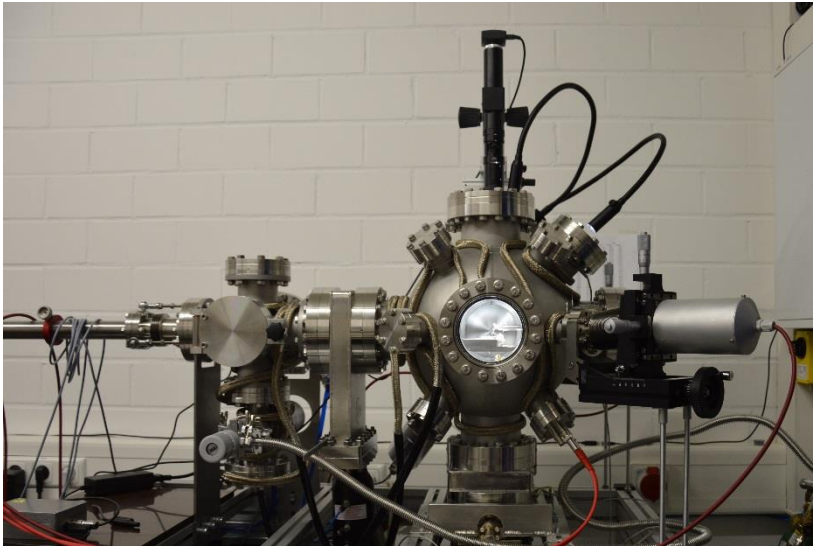
- low operation voltage
- high emission currents
- stable, homogeneous and low-noise emission

2. Setup of the field emission electron source

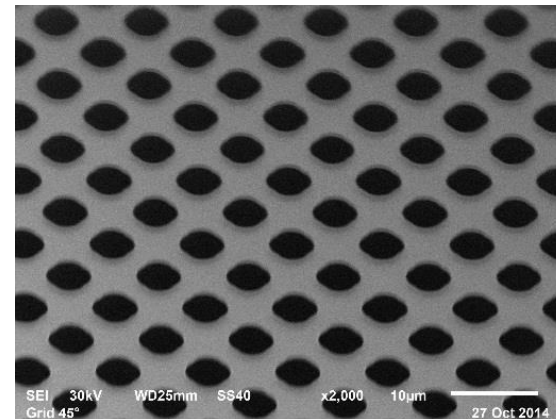
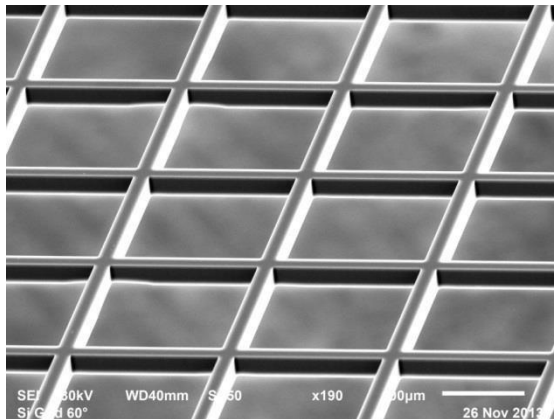
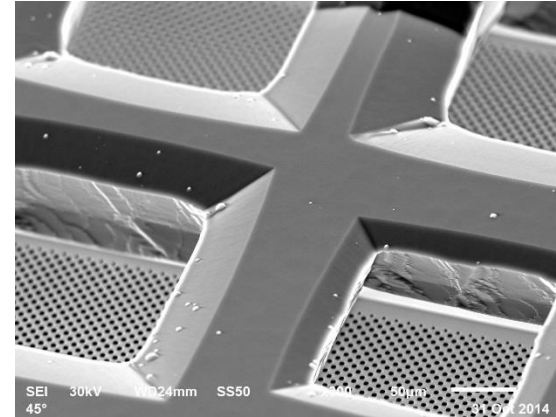
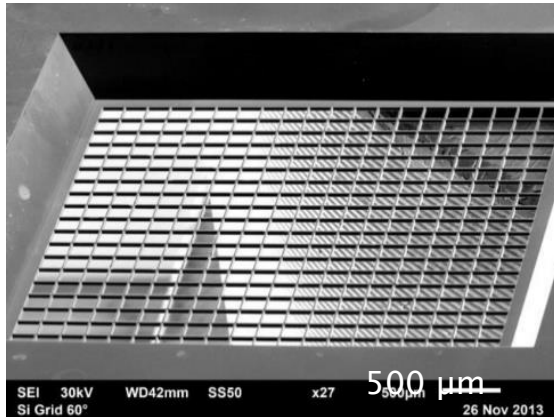


2. Setup of the field emission electron source

Vacuum measurements



2. Setup of the field emission electron source



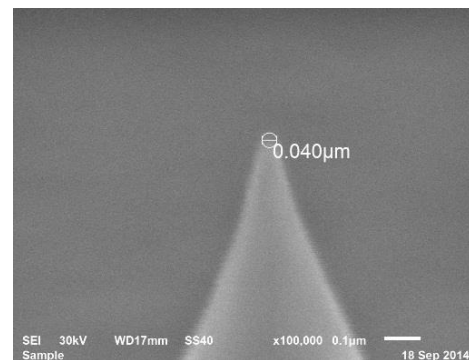
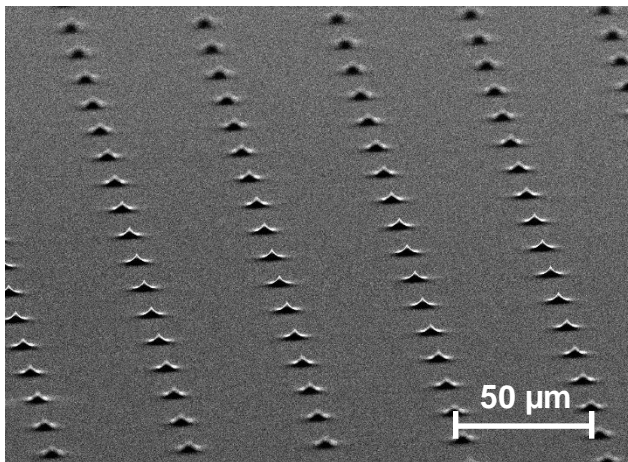
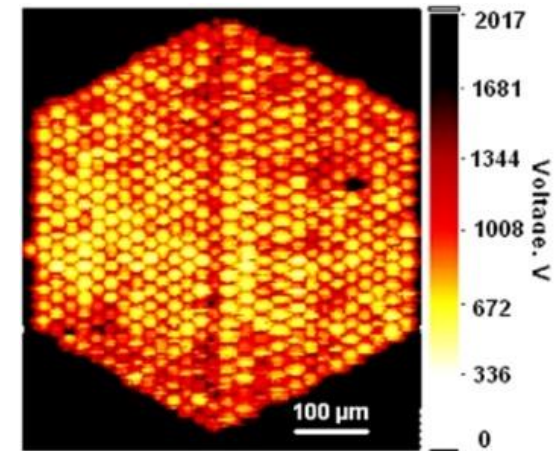
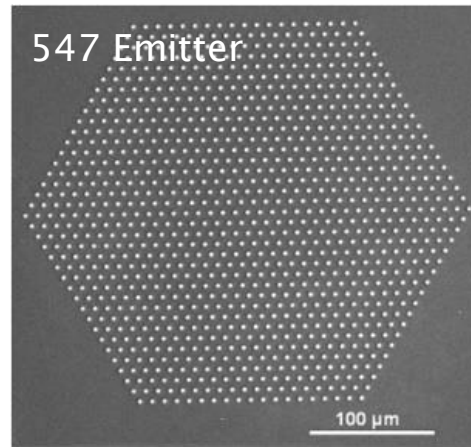
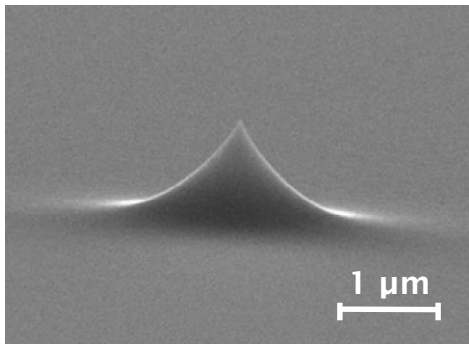
High transmission

Homogeneous field distribution

3. Si-based field emission cathodes

Conventional p-type Si tip Arrays

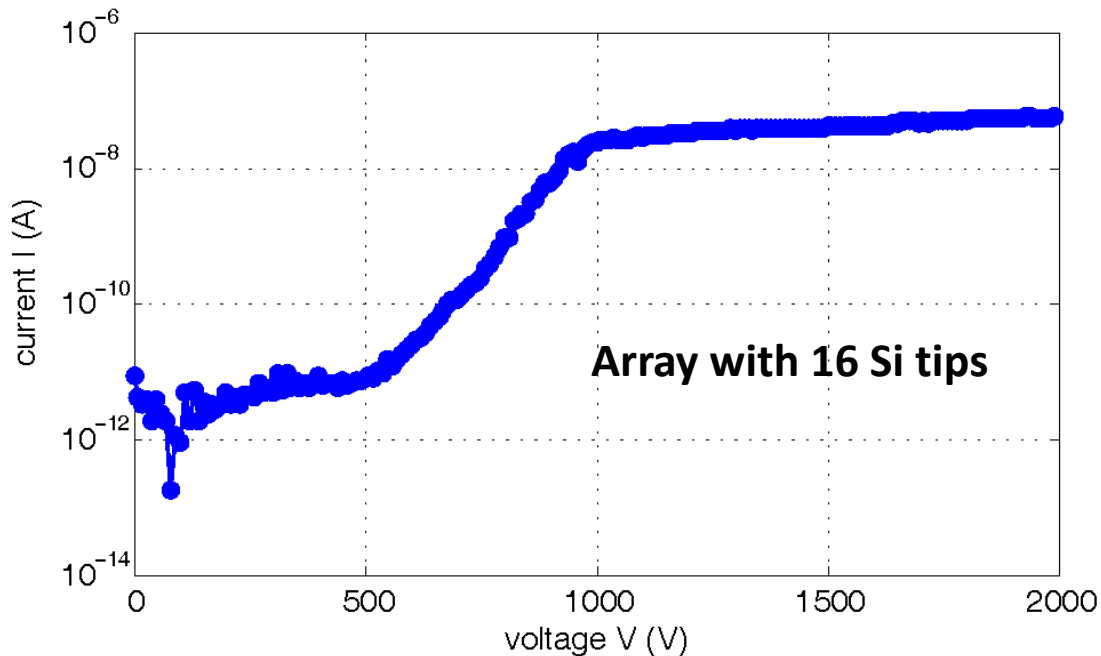
$h = 1 \mu\text{m}$, 1 nA , $Z_0 \approx 8 \mu\text{m}$, $\phi_{\text{anode}} = 3 \mu\text{m}$



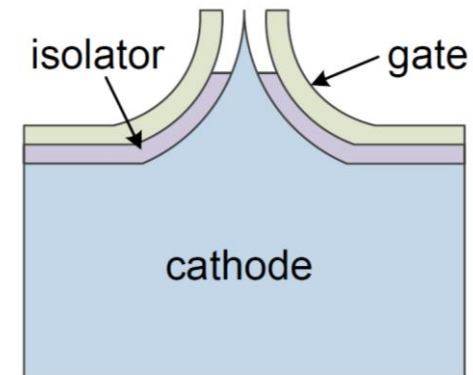
**Homogeneous emission
over large areas**

3. Si-based field emission cathodes

Conventional p-type Si tip Arrays



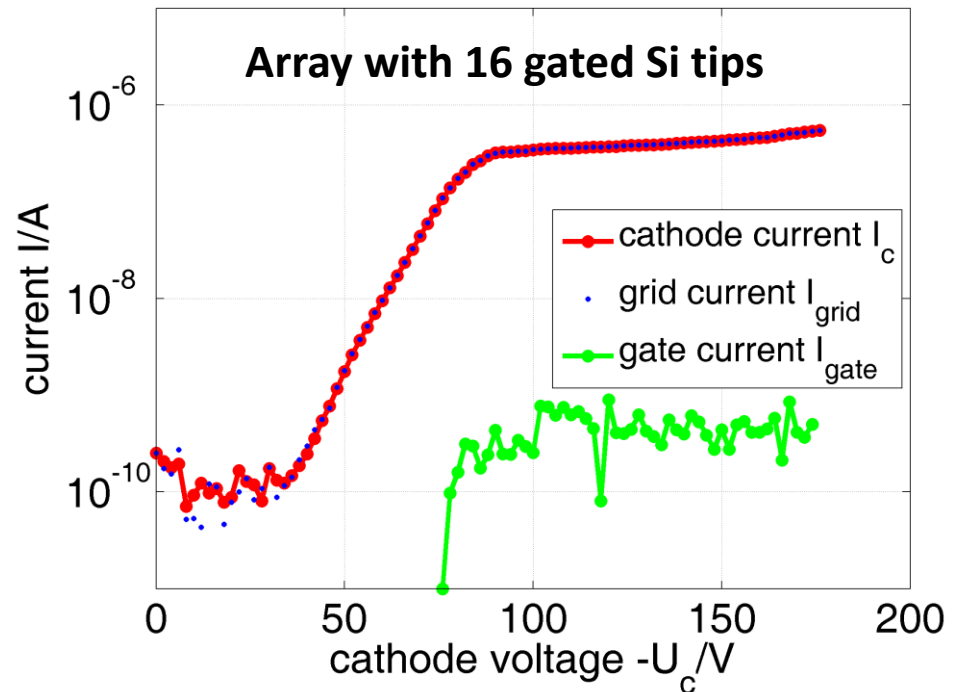
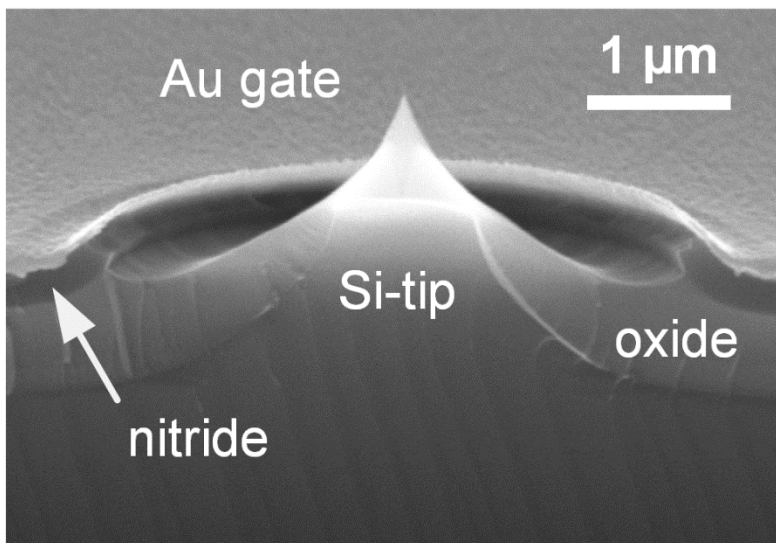
- high operation voltage
- p-doped Si shows a saturation region



-> Integration of a gate-electrode close to Si-tip structure

3. Si-based field emission cathodes

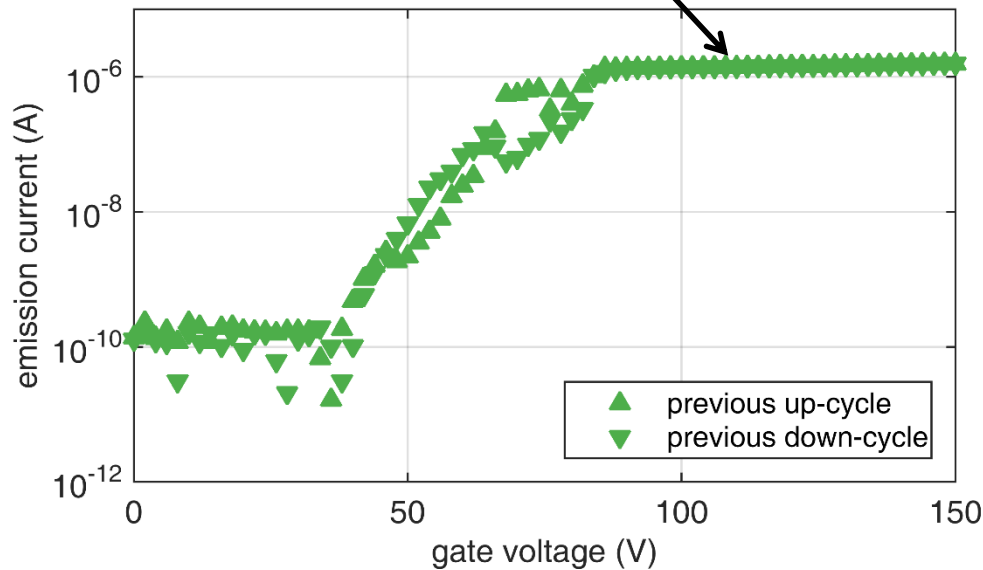
p-type Si tip Arrays with integrated gate electrode



- negligible gate current I_{gate}
- nearly all e^- reaching the grid anode

3. Si-based field emission cathodes

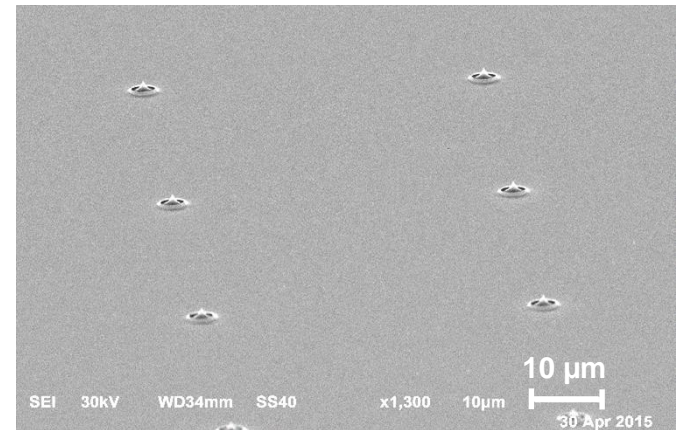
Pronounced saturation effect



Pre-characterization:

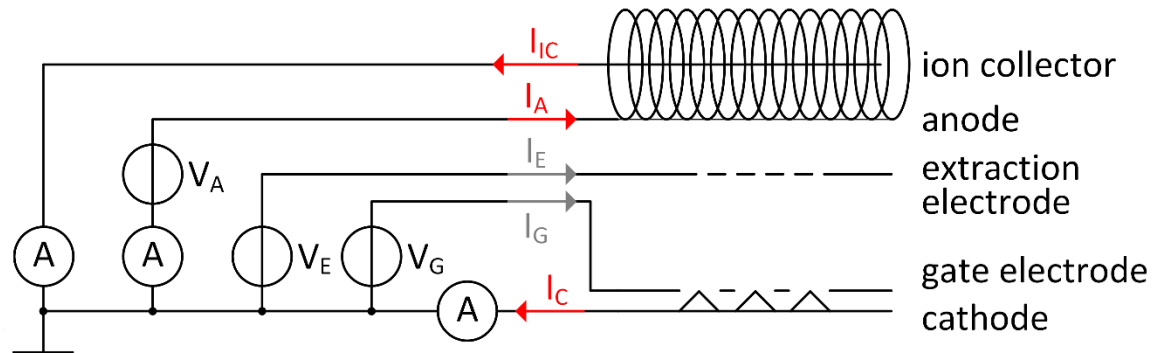
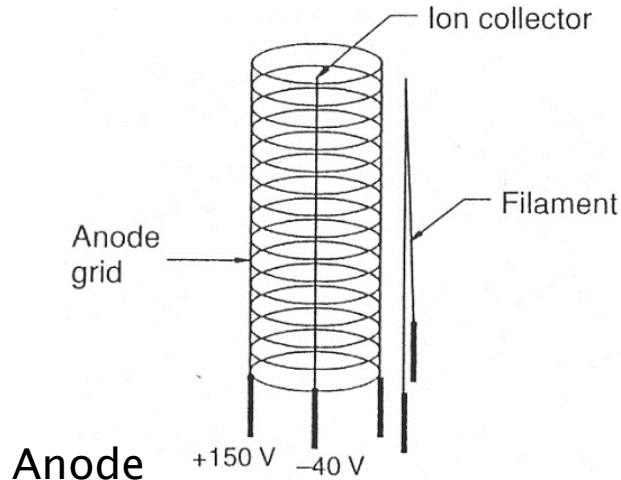
Saturation regime at $V_{\text{Gate}} > 80 \text{ V}$

Emission current of $1.6 \mu\text{A}$ @ 150 V

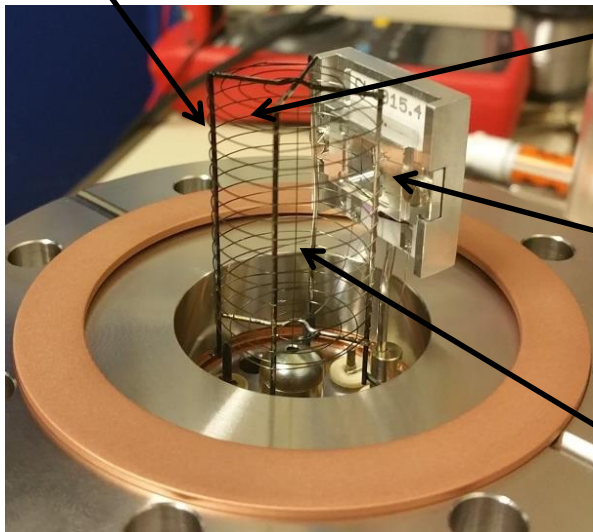


- Low operation voltages
- High emission currents
- Stable and homogeneous emission currents

4. Application in an ionisation vacuum gauge



Anode



Ionisation of the residual gas

FE electron source

Ion collector

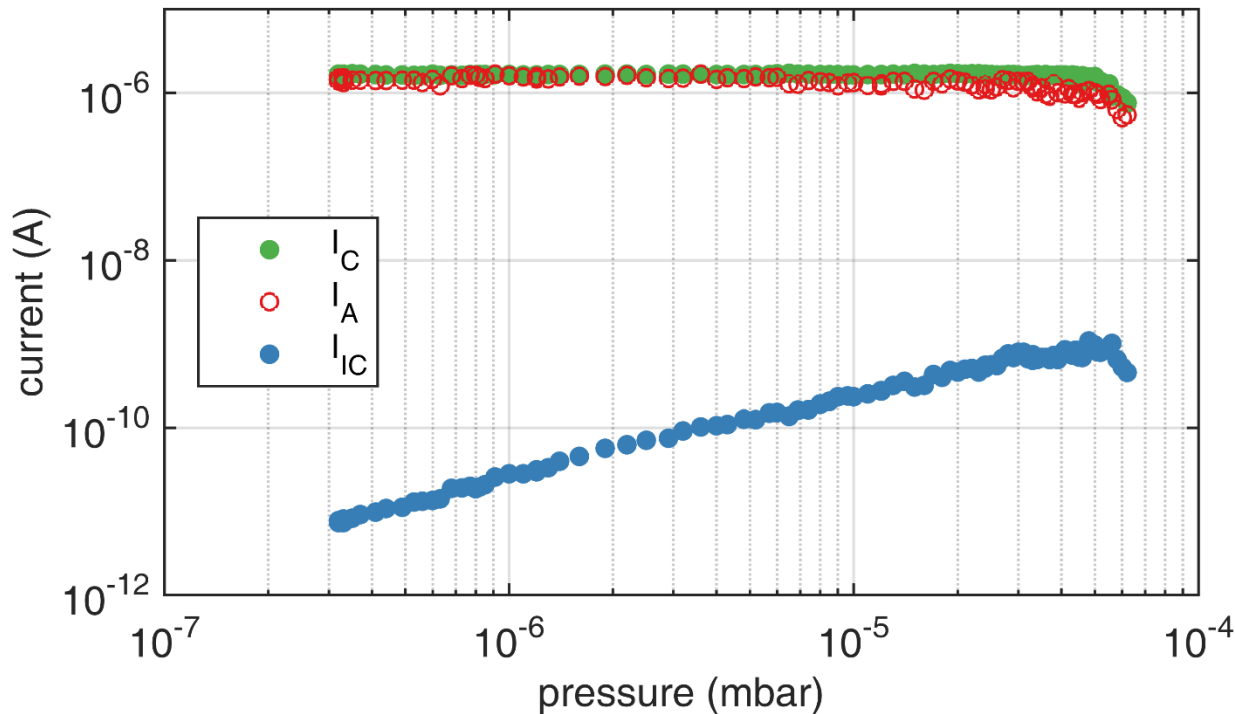
Ion collector = 0 V
Anode voltage = 500 V
Grid voltage = 400 V
Gate voltage = 150 V

FE electron source as a replacement for the hot filament

4. Application in an ionisation vacuum gauge

Measurement results

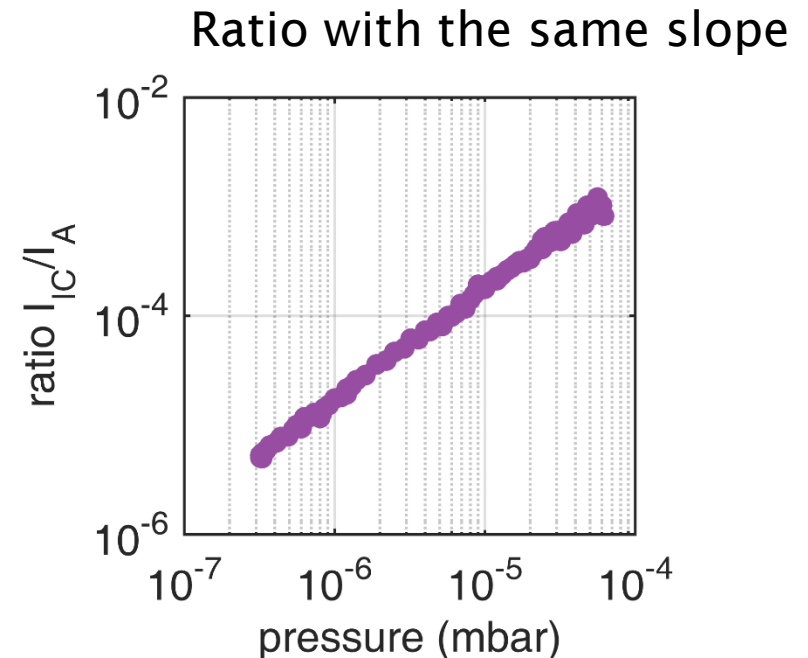
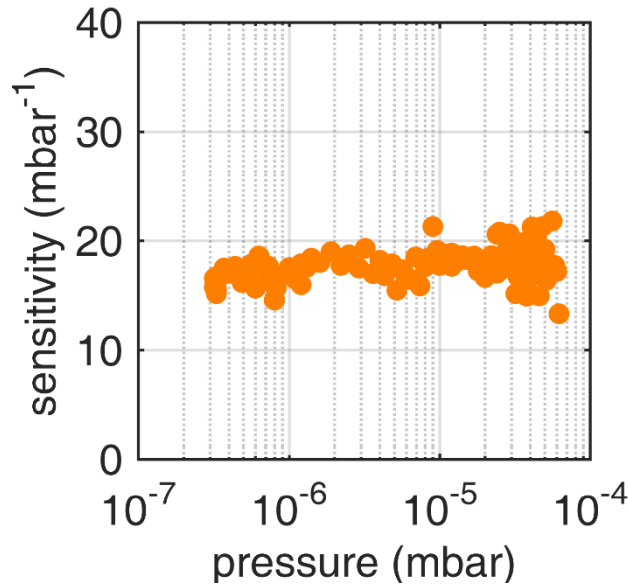
$$\text{Ion collector current } I_{IC} = I_A * S * p$$



Anode current of 1.3 μ A led to an ion current I_{IC} of 7 fA (@ 3×10^{-7}) and of 0.8 pA (@ 4×10^{-5} mbar)

4. Application in an ionisation vacuum gauge

Measurement results



Mean value of sensitivity S of 17.6 mbar^{-1}

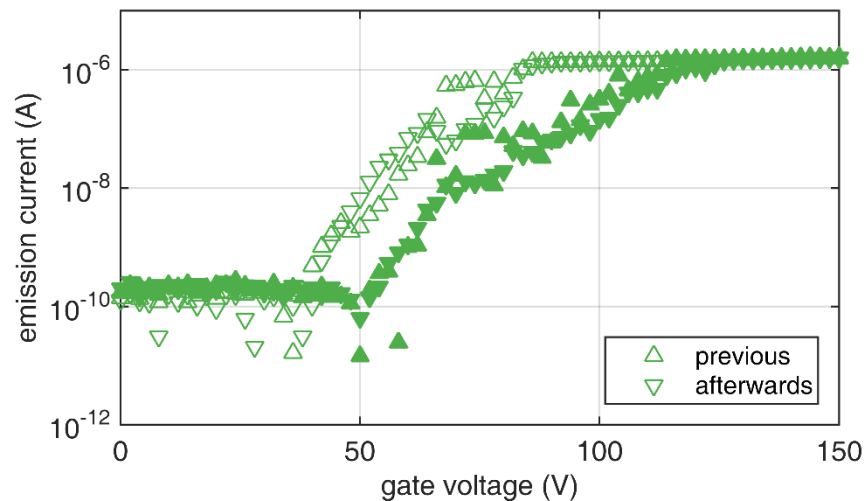
Good agreement with given value of 17 mbar^{-1} by the manufacturer for this ionization gauge with hot filament

4. Application in an ionisation vacuum gauge

Characterization of the electron source

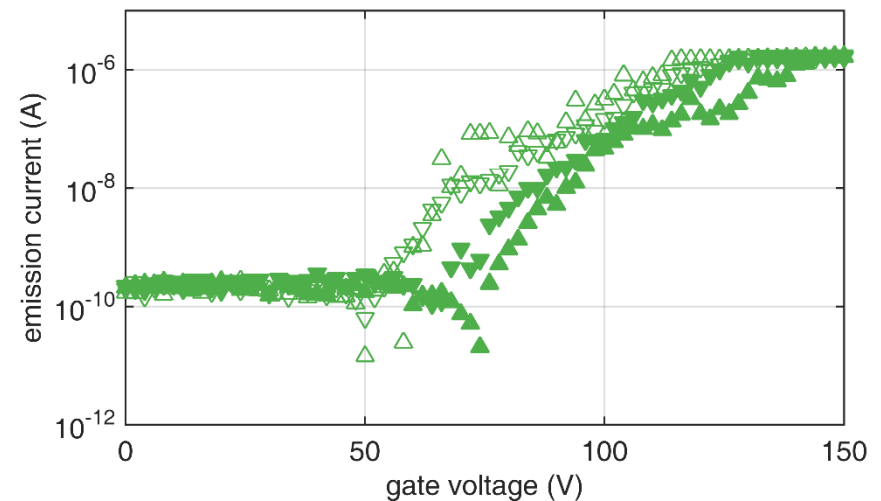
p up to 6×10^5 mbar

After 2 sweeps



- Slightly degradation
- Saturation regime at $V_{\text{Gate}} > 120$ V

After 3 sweeps



- Further degradation
- Saturation regime at $V_{\text{Gate}} > 130$ V

5. Conclusion

1. We developed a setup of a field emission electron source
2. Our conventional Si tip arrays showed homogeneous FE, but high operation voltages were required
3. A significant reduction of the operation voltage was possible with our Si tip arrays with integrated gate electrode
4. The FE electron source showed a very stable and reproducible field emission behavior and a hot filament in a ionisation vacuum gauge was replaced
5. Our electron source is applicable in a commercial BA ionisation vacuum gauge even in harsh environments (pressures up to 10^{-5} mbar)

Thank you for your attention

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